THE VISUALIZATION OF POWER DENSITY AND TEMPERATURE DISTRIBUTION OF ELECTRONIC SYSTEM USING ELLIPTIC PDE SOLVER

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Abstract: The visualization of power density and temperature are critical in electronic-chip industries. Taking the advantages of mathematical algorithm that is based on elliptic equation of partial differential equation (PDE), the two-dimensional simulation has successfully been generated. The numerical iterative methods that are being used results in efficient elliptic PDE solvers. Numerical analysis is done in terms of execution time, number of iterations and computational complexity of the algorithm being used. The comparison is done between two iterative methods which are Gauss-Seidel and Red-Black Gauss Seidel. The elliptic solver is developed using C language and executed in Linux operating system's environment.

Keywords: full-chip thermal simulation, elliptic equation, power density distribution, temperature visualization, multilayered architecture.

1. INTRODUCTION

The increasing needs in managing energy efficiency in electronic-chip industries drives the route of research to produce efficient tools for predicting on-chip temperature behavior. The power and temperature visualization involves large scale of computational complexity and consuming lots of execution time. In this paper, the visualization of power density behavior and temperature distribution for multi-layer full-chip structure is being focused on. Figure 1 shows the packaging of multilayer full-chip structure including the heat spreader and heat sink are explicitly shown in the model below.



Figure 1: Simplified model of the multilayered full-chip structure

The solution that is based on numerical computational mathematics proposed the development of partial differential equation based on Poisson's equation of two dimensional elliptic equations. The equation is discretized using Finite Difference Method (FDM) in order to transform it into matrix form.

2. MATHEMATICAL MODELING

Temperature distribution inside the multilayered chip is governed by the following Poisson's equation.

$$\frac{\partial^2 u}{\partial x^2} + \frac{\partial^2 u}{\partial y^2} = f(x, y)$$
(1)

Where f(x, y) is the function introduced in [2]. The function introduced is as follows:

$$f(x, y) = -\frac{g(x, y)}{k_{l(x, y)}}$$
(2)

With g(x, y) represent power density distribution on the multilayer full-chip and $k_{l(x,y)}$ is thermal conductivity of the layer at point x, y. Whereas, the discretization of (1) results in

$$\frac{u_{i+1,j} - 2u_{i,j} + u_{i-1,j}}{h^2} + \frac{u_{i,j+1} - 2u_{i,j} + u_{i,j-1}}{k^2} = f(x, y)$$
(3)

$$u_{i+1,j} + u_{i-1,j} + pu_{i,j+1} - (2+2p)u_{i,j} + pu_{i,j-1} = f(x, y)$$
(4)

Where $p = \frac{h^2}{k^2}$

Assume that the chip is $M \times N$ of grid size and from [2] the on-chip power density distribution can be referred as

Jilid 20, Bil. 3 (Disember 2008)

$$P_{ij} = \sum_{m=0}^{M-1} \sum_{n=0}^{N-1} \cos\left(\frac{i\pi(2m+1)}{2M}\right) \cos\left(\frac{j\pi(2n+1)}{2N}\right)$$
(5)

3. NUMERICAL METHODS

To numerically solve equation (4), we use the iterative methods which are Gauss-Seidel and Red-Black Gauss-Seidel. A brief description for both methods is given below.

3.1 Gauss Seidel Method (GS)

Gauss Seidel method represents an improved version of Jacobi method in solving the system of linear equations, AU=f. This method coined by the German mathematicians Carl Friedrich Gauss and Philipp Ludwig von Seidel. By using previously computed results as soon as they become available, this implementation is explicitly shown in the following pseudocode.

```
Set number of iterations

Calculations of equation (5)

For round: = 1 increase 1 until numbers of iterations do

Initial values

For timestep :=1 until convergence criterion met do

For i=lincrease 1 until matrix size do

For j=l increase until matrix size do

u_{i+1,j} + u_{i-1,j} + u_{i,j+1} - 4u_{i,j} + u_{i,j-1} = f(x,y)

End loop j

End loop j

End loop i

Check convergence

End loop timestep

End loop round
```

3.2 Red-Black Gauss Seidel Method

Red-Black Gauss-Seidel method represents the same computational way as Gauss Seidel method. The only difference is that this method divides the computation into two sub-regions

Figure 2: Pseudocode of Gauss-Seidel Iteration Method

which are odd and even. The divisions of the regions are as shown in the following pseudocode:

```
Set number of iterations
Calculations of power
For round: = 1 increase 1 until maximum number of iterations (k)
do
Initial values
       For timestep :=1 until convergence criterion met do
             For i= 1 increase until matrix size do
                 For j=1 increase until matrix size do
                     If odd, do
                    u_{i+1,j} + u_{i-1,j} + u_{i,j+1} - 4u_{i,j} + u_{i,j-1} = f(x,y)
                 End loop j
             End loop i
             For i=lincrease 1 until matrix size do
                 For j=1 increase until matrix size do
                       If even, do
                          u_{i+1,j} + u_{i-1,j} + u_{i,j+1} - 4u_{i,j} + u_{i,j-1} = f(x, y)
                 End loop j
             End loop i
                 Check convergence
           End loop timestep
End loop round
```

Figure 3: Pseudocode of Red-Black Gauss-Seidel Iteration Method

4. TEMPERATURE ALGORITHM



Figure 4: Sequential algorithm of parabolic equation

Figure 4 shows the computational flow in calculating the temperature of multilayer full-chip architecture. The item *count* is the number of iterations taken in order to fulfill the stopping criterion. Variable *round* is being referred as the number of time step in calculating U_{η} value.

5. NUMERICAL RESULTS AND ANALYSIS

The two-dimensional visualization of power and temperature distribution for multilayer fullchip architecture is shown in figure 5 and 6. Visualization of graph (figure 5) is based on equation (5) and the graph of temperature (figure 6) is the result gained from equation (1). While figure 7 shows the three-dimensional visualization of the temperature profile using COMSOL Multiphysics software.

x/y	0	1	2	3	4	5	6	7	8	9
0	201.95	203.71	205.11	206.00	206.31	206.00	205.11	203.71	201.95	200.00
1	201.76	203.35	204.61	205.42	205.70	205.42	204.61	203.35	201.76	200.00
2	201.40	202.66	203.66	204.30	204.52	204.30	203.66	202.66	201.40	200.00
3	200.90	201.71	202.35	202.76	202.90	202.76	202.35	201.71	200.90	200.00
4	200.31	200.59	200.81	200.95	201.00	200.95	200.81	200.59	200.31	200.00
5	199.69	199.41	199.19	199.05	199.00	199.05	199.19	199.41	199.69	200.00
6	199.10	198.29	197.65	197.24	197.10	197.24	197.65	198.29	199.10	200.00
7	198.60	197.34	196.34	195.70	195.48	195.70	196.34	197.34	198.60	200.00
8	198.24	196.65	195.39	194.58	194.30	194.58	195.39	196.65	198.24	200.00
9	198.05	196.29	194.89	194.00	193.69	194.00	194.89	196.29	198.05	200.00

Table 1: Power density distribution based on grid value

Table 2: Temperature distribution based on grid value

x/y	0	1	2	3	4	5	6	7	8	9
0	28.00	28.00	28.00	28.00	28.00	28.00	28.00	28.00	28.00	28.00
1	28.00	133.48	181.42	196.61	204.82	203.60	202.44	195.48	179.93	142.96
2	28.00	180.60	248.17	281.48	286.85	290.82	285.59	276.13	250.61	194.51
3	28.00	194.60	279.80	309.06	324.17	322.73	320.49	307.88	279.03	214.80
4	28.00	201.61	283.24	321.92	330.37	334.29	329.42	318.00	287.64	221.29
5	28.00	199.41	285.48	318.24	331.79	332.58	330.04	318.28	288.54	222.04
6	28.00	197.66	279.03	314.17	324.64	327.52	324.51	313.88	284.92	219.70
7	28.00	190.65	269.08	300.50	311.59	313.68	311.56	301.69	274.67	212.19
8	28.00	175.63	244.03	271.69	280.69	282.84	281.02	272.82	249.07	193.42
9	28.00	139.87	189.55	208.99	215.46	216.87	215.71	209.66	192.36	150.17



Figure5: Power density distribution



Figure 6: Prediction of temperature behavior



Figure 7: Visualization of temperature using COMSOL Multiphysics software

The on-chip temperature distribution is dependent on the value of power density given to the chip. The advantages of the temperature prediction are to reduce the numbers of rejected fullchip. In chip industry, the process in visualizing the power and temperature distribution on multilayered chip involves large scale of computational complexity. Therefore, we develop the algorithm introduced in [2] using C language on Linux platform. Development of the algorithm in C language makes it possible for future advancement of the algorithm in distributed computing environment. Distributed computing will reduced the visualizing process complexity where the task is distributed to several processors and produce the results in less time compared to running the code on a single processor. In addition, using Linux as operating system platform will ensure the low-cost implementation, since it is from an open source environment where no licensing procedure required.

Table 3: Comparison of Numerical Analysis

Method	Gauss Seidel	Gauss Seidel Red Black			
Analysis	1				
Execution time (microsecond)	626	624			
Iteration	9000	200			
Computational complexity:					
Add	27000	600			
Divide	9000	200			

Table 3 shows the comparison of numerical analysis between the calculation using Gauss-Seidel and Red-Black Gauss Seidel methods. The comparison is done in terms of execution time, number of iterations and computational complexity. The analysis shows that Red-Black Gauss Seidel is significantly better than Gauss-Seidel method. This is because, Red-Black Gauss Seidel results in small value of every term that is to be analyzed.

6. CONCLUSION

The novelty of this research is the two-dimensional visualization of power density and temperature distribution for multilayered full-chip structure governing by elliptic equation. This research will be potentially enhanced by implementing parallel algorithm of the power density and temperature visualization on distributed parallel computer system. Development of the algorithm in C language on Linux operating system is an added value and bright potential for further advancement in parallel and grid computing environment.

ACKNOWLEDGMENT

The authors acknowledge the Institute of Ibnu Sina, Fundamental Science Studies, UTM and Ministry of Science, Technology and Innovation Malaysia (MOSTI) for the financial support under vote 79217.

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